NOTES:

- 1. SUBSTRATE: UV FUSED SILICA
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- 3. COATING (APPLY ACROSS COATING APERTURE)

\$1: HARD DIELECTRIC SPUTTERED

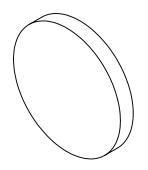
T(avg): \geq 91% FROM 1120 - 1650nm @ 0° AOI
T(avg): \section 0.01% FROM 200 - 1080nm @ 0° AOI
T(abs): =50% FOR 1100±11nm @ 0° AOI

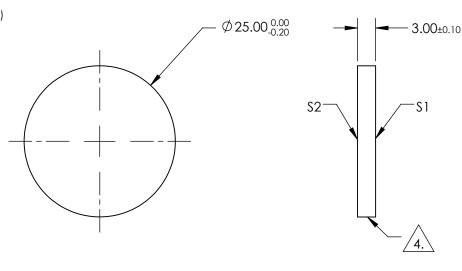
S2:SINGLE LAYER MgF2

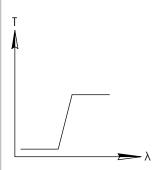
4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm (prior to coating)
- 7. ROHS COMPLIANT









LONGPASS FILTER

	\$1	\$2	
SHAPE	PLANO	PLANO	
SURFACE QUALITY	60-40	60-40	
CLEAR APERTURE	>80%	>80%	
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED	

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

Edmund Optics®

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THIRD ANGLE PROJECTION		TITLE	Ø25mm, 1100nm, HIGH PERFORMANCE LONGPASS FILTER		
ALL DIMS IN	mm	DWG NO	66241	SHEET 1 OF 1	